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Attorney Docket No.: 0180151

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of: Labelle, et al.

Serial No.: 10/705,347

Filed: November 8, 2003

For: Method for Integrating a High-K Gate

Dielectric in a Transistor Fabrication

Process

Art Unit: 1765

Examiner: Chen, Kin-Chan

RCE (37 CFR §1.114) AND REQUEST TO REOPEN PROSECUTION UNDER 37 CFR §1.198 AND MPEP §1214.07

Mail Stop RCE Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Dear Sir/Madam:

Applicant has received a final decision dated March 16, 2007 from the Board of Patent Appeals and Interferences on appeal. Applicant hereby requests that the prosecution of the present application be reopened under provisions of 37 CFR §1.198 and MPEP §1214.07, which permit the Applicant to reopen prosecution by submitting a request for continued examination (RCE) under 37 CFR §1.114. Accordingly, Applicant respectfully requests that the following amendments and remarks be entered in the present

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application and that the amended claims be examined for an early allowance in the present application.